- INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)					Docket Number (Optional)		Application Number			
					YOR920020093US3 (16343ZY) Applicant(s)		Unassigned			
					Marie Angelopoulos, et al.					
					Filing Date Herewith	Group Art Unit Unassigned				
U.S. PATENT DOCUMENTS										
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE		NAME	CLASS	SUBCLASS	FILING IF APPRO		
DR		6,395,433	05/28/02	Smith		430	5			
20		6,309,780	10/30/01	Smith		430	5			
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FOREIGN PATENT DOCUMENTS										
	REF	DOCUMENT NUMBER DATE			COUNTRY	CLASS	SUBCLASS	Translation YES NO		
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)										
<u> </u>	Burn, J. Lin, "The Attenuated Phase-Shifting Mask", Solid State Technology, January 1992, pp. 43-47									
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.	Liberman, V. et al., "Materials Issues For Optical Components And Photomasks In 157 NM Lithography", J. Vac. Sci. Technol. B17, November/December 1999, pp. 3273-3279									
EXAMINER A COSCO					DATE CONSIDERED 8/1/04					
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.										
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